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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/538,525	06/10/2005	Geoffrey Harding	PHNL031185US	3670
24737 PHILIPS INTE	7590 08/06/2007 ELLECTUAL PROPER		EXAMINER	
P.O. BOX 3001 ARTMAN, THOMAS				
BRIARCLIFF	MANOR, NY 10510		ART UNIT	PAPER NUMBER
			2882	
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			08/06/2007	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

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	Application No.	Applicant(s)	
Office Antique Occurrence	10/538,525	HARDING, GEOFFREY	
Office Action Summary	Examiner	Art Unit	
	Thomas R. Artman	2882	
The MAILING DATE of this communication a Period for Reply	appears on the cover sheet wit	th the correspondence address	
A SHORTENED STATUTORY PERIOD FOR REF WHICHEVER IS LONGER, FROM THE MAILING - Extensions of time may be available under the provisions of 37 CFR after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perions for perions of the period for reply within the set or extended period for reply will, by state Any reply received by the Office later than three months after the material patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNIC 1.136(a). In no event, however, may a re od will apply and will expire SIX (6) MONI tute, cause the application to become ABA	CATION. sply be timely filed IHS from the mailing date of this communicat ANDONED (35 U.S.C. § 133).	
Status			
 1) Responsive to communication(s) filed on 24 2a) This action is FINAL. 2b) The 3 Since this application is in condition for allow closed in accordance with the practice under the condition of the condition of	his action is non-final. vance except for formal matte		is
Disposition of Claims	Lix parte Quayre, 1999 O.D.	11, 400 0.0. 210.	
4)	rawn from consideration.		
Application Papers			
9)☐ The specification is objected to by the Exami 10)☒ The drawing(s) filed on 10 June 2005 is/are: Applicant may not request that any objection to the Replacement drawing sheet(s) including the correction. The oath or declaration is objected to by the	a)⊠ accepted or b)⊡ object the drawing(s) be held in abeyand ection is required if the drawing(ce. See 37 CFR 1.85(a). s) is objected to. See 37 CFR 1.121	(d).
Priority under 35 U.S.C. § 119			
 12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure * See the attached detailed Office action for a light content. 	ents have been received. ents have been received in Apriority documents have been eau (PCT Rule 17.2(a)).	oplication No received in this National Stage	
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s	ummary (PTO-413))/Mail Date	
Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	5) Motice of In 6) Other:	formal Patent Application —·	

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DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on June 20th, 2007, has been entered.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1, 3-15, 17 and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Whitaker (US 4,622,687) in view of Arndt (US 6,282,263 B1).

Regarding claims 1, 14 and 15, Whitaker discloses an X-ray source (Figs.1, 3 and 15), including:

- a) an electron source 153 for the emission of electrons,
- b) a target 20 for the emission of characteristic, substantially monochromatic X-rays in response to the incidence of the electrons, the target being made of a metal foil 149, 151 having a high atomic number allowing the generation of X-rays 145, and

c) an outcoupling means (not shown) for outcoupling the X-rays on the side of the metal foil on which the electrons are incident and which is opposite to the side of the base arrangement (Fig.15).

Whitaker does not specifically disclose that the metal foil has a thickness of 10 µm or less, and further that the target has a base arrangement being made of a material having a low atomic number such that X-rays are not generated from the base arrangement.

Arndt specifically teaches the practice of forming a target 4 as a metal foil upon a base arrangement made of carbon (col.6, lines 5-18), where the metal foil is less than 10 µm thick. In this way, the target is more efficiently cooled in order to operate the X-ray source for longer periods of time and/or at higher energies, as needed (col.6, lines 14-18).

It would have been obvious to one of ordinary skill in the art at the time the invention was made for Whitaker to add a base arrangement of carbon and make the metal foil 10 µm or less, as taught by Arndt, in order to greatly increase the cooling efficiency of the target.

Further regarding claims 1 and 14, the Whitaker/Arndt combination results in a base arrangement that is rotatable and includes carbon, a material with an atomic number less than 10.

With respect to claims 3-5 and 17, both Whitaker and Arndt disclose a cooling circuit as part of the base arrangement (Figs.3 and 15 of Whitaker; Fig.2; col.4, lines 31-34 and 37-38 of Arndt), where coolant flows along the side of the metal foil opposite to the side on which the electrons are incident.

However, Whitaker does not specifically disclose the type of coolant.

Arndt specifically teaches the use of water as a coolant, a coolant having a mean atomic number less than 10. Water is cheap and plentiful, as is known in the art, and water also has a high heat capacity, making it an economical and efficient choice of coolants.

It would have been obvious to one of ordinary skill in the art at the time the invention was made for Whitaker to use water as a coolant, as taught by Arndt, in order to provide a costeffective and efficient cooling system for the anode.

With respect to claims 6 and 18, Whitaker further discloses a constriction in the cooling circuit in the area 43 of the metal foil (Fig.3).

With respect to claim 7, the Whitaker/Arndt combination results in a base arrangement that includes carbon, a material with an atomic number less than 10.

With respect to claim 8, Arndt teaches that the metal foil has a thickness less than 5 µm.

With respect to claim 9, Whitaker does not specifically disclose the material of the target.

Arndt teaches that the metal of the foil target has an atomic number between 40 and 80 depending upon the desired wavelength(s) (col.4, lines 25-28).

It would have been obvious to one of ordinary skill in the art at the time the invention was made for Whitaker to use a target material for the metal foil having an atomic number between 40 and 80, as taught by Arndt, in order to achieve a desired output wavelength, as taught by Arndt.

With respect to claim 10, Whitaker further discloses that the outcoupling means is adapted to outcouple X-rays at an angular range from substantially 45 to 135 degrees (Fig.15).

With respect to claim 11, Whitaker further discloses that the outcoupling means is adapted to outcouple X-rays in a direction substantially antiparallel to the direction if incidence of the electrons (Fig.15).

With respect to claim 12, Whitaker further discloses that the electrons are directed onto the surface of the metal foil at a substantially 90 degree angle (Fig.3).

With respect to claim 13, Whitaker further discloses that the electron source is located outside the X-ray beam (Fig.15) to be outcoupled, and the X-ray source has means for directing the electron beam onto the metal foil (cathode).

Claim 20 is rejected under 35 U.S.C. 103(a) as being unpatentable over Whitaker and Arndt, as applied to claim 1 above, in view of Wilson (US 6,947,522 B2).

Whitaker and Arndt do not specifically disclose that the outcoupled x-rays are approximately 150 to 210 degrees from the incident electrons. However, Arndt does teach that the target may be inclined to the incident electron beam in order to reduce the absorption of emitted x-rays (col.4, lines 28-30).

Wilson specifically teaches an x-ray source arrangement (Fig.4) where the incident electron beam 82 is nearly parallel with the surface 80 of the anode layer 52. In this

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arrangement, the emitted x-rays 90 (outcoupled through window 34, Fig.1) are within the range of 150 to 180 degrees from the incident electron beam (col.4, line 60 through col.5, line 11). The arrangement provides the ability to control overheating of the anodes (col.2, lines 33-36). It is also readily recognized by the skilled artisan that the inclination will also provide the advantage taught by Arndt, where the absorption of the emitted x-rays, by the target, is greatly reduced in that angular range.

It would have been obvious to one of ordinary skill in the art at the time the invention was made for Whitaker to incline the metal foil such that the outcoupling means outcouples xrays at an angle between 150 and 210 degrees from the incident electron beam, as taught by Wilson, in order to effectively mitigate x-ray absorption by the target, as taught by Arndt, and to effectively mitigate overheating of the target, as taught by Wilson.

Response to Arguments

Applicant's arguments filed June 20th, 2007, have been fully considered but they are not persuasive.

The prior art combination of Whitaker in view of Arndt renders claims 1, 14 and 15 obvious for reasons as stated in the Final Rejection, dated 5/9/07. Whitaker has a fluid-cooled metal x-ray target on a rotating base plate, and Arndt specifically teaches thin x-ray targets (10 microns or less) mounted upon diamond substrates (carbon, atomic number less than 10) for the purpose of improving the cooling efficiency of the target when cooled with fluid (see col.4, lines 25-50 and col.6, lines 5-18 of Arndt).

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Furthermore, the present amendments to claims 1, 14 and 15 do not distinguish the claimed invention over the prior art. Both Whitaker and Arndt specifically teach reflection x-ray targets and x-ray windows that extract x-rays from the reflection side of the target surface (opposite the coolant side, see at least Figs.1 and 2 of Arndt and Figs.3 and 15 of Whitaker).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Thomas R. Artman whose telephone number is (571) 272-2485. The examiner can normally be reached on 9am - 5:30pm Monday - Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ed Glick can be reached on (571) 272-2490. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

Thomas R. Artman Patent Examiner

EDWARD J.GLICK
SUPERVISORY PATENT EXAMINER